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Permalink
https://escholarship.org/uc/item/9195n4zp

Journal
Physical Review B, 94(9)

ISSN
2469-9950

Authors
Kuschel, O
Buß, R
Spiess, W
et al.

Publication Date
2016-09-20

DOI
10.1103/PhysRevB.94.094423

Peer reviewed
From Fe$_3$O$_4$/NiO bilayers to NiFe$_2$O$_4$-like thin films through Ni interdiffusion


1Department of Physics, Barbarastrasse 7, Osnabrück University, 49076 Osnabrück, Germany
2Advanced Light Source, Lawrence Berkeley National Laboratory, California 94720, USA
3Center for Spinelectronic Materials and Devices, Department of Physics, Bielefeld University, 33615 Bielefeld, Germany
4Physics of Nanodevices, Zernike Institute for Advanced Materials, University of Groningen, 9747 AG Groningen, Netherlands
5Center of Physics and Chemistry of New Materials, Osnabrück University, 49076 Osnabrück, Germany

(Received 9 February 2016; revised manuscript received 1 July 2016; published 20 September 2016)

Ferrites with (inverse) spinel structure display a large variety of electronic and magnetic properties, making some of them interesting for potential applications in spintronics. We investigate the thermally induced interdiffusion of Ni$^{2+}$ ions out of NiO into Fe$_3$O$_4$ ultrathin films, resulting in off-stoichiometric nickel ferrite–like thin layers. We synthesized epitaxial Fe$_3$O$_4$/NiO bilayers on Nb-doped SrTiO$_3$(001) substrates by means of reactive molecular beam epitaxy. Subsequently, we performed an annealing cycle comprising three steps at temperatures of 400 °C, 600 °C, and 800 °C under an oxygen background atmosphere. We studied the changes of the chemical and electronic properties as result of each annealing step with help of hard x-ray photoelectron spectroscopy and found a rather homogeneous distribution of Ni and Fe cations throughout the entire film after the overall annealing cycle. For one sample we observed a cationic distribution close to that of the spinel ferrite NiFe$_2$O$_4$. Further evidence comes from low-energy electron diffraction patterns indicating a spinel-type structure at the surface after annealing. Site- and element-specific hysteresis loops performed by x-ray magnetic circular dichroism uncovered the antiferromagnetic alignment between the octahedral coordinated Ni$^{2+}$ and Fe$^{3+}$ ions and the Fe$^{3+}$ ion in tetrahedral coordination. We find a quite low coercive field of 0.02 T, indicating a rather low defect concentration within the thin ferrite films.

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I. INTRODUCTION

Iron oxides are of special interest due to a number of astonishing properties dependent on the Fe valence state and the underlying crystallographic and electronic structure. Magnetite (Fe$_3$O$_4$) is among the most studied ferrites due to its ferrimagnetic ordered ground state with a saturation moment of 4.07μB per formula unit and a high Curie temperature of 860 K for bulk material [1,2]. This magnetic ground state is accompanied by half metallicity; that is, only one spin orientation is present at the Fermi energy [3], making this is accompanied by half metallicity; that is, only one spin orientation is present at the Fermi energy [3], making this question or the tunnel magnetoresistance in magnetic tunnel junctions with magnetite electrodes [15–18].

A potential approach to minimize or suppress Mg segregation, besides rather low substrate temperatures during magnetite growth, is an additional buffer layer, e.g., metallic iron [19] or NiO [20] between Fe$_3$O$_4$ and the substrate. This approach is also of interest with respect to the possibility of building a full oxidic spin valve making use of the exchange bias between the ferrimagnetic magnetite and the antiferromagnetic nickel oxide [20–22].

The usage of other substrates like SrTiO$_3$ could also prevent Mg interdiffusion. Despite the large lattice mismatch of −7.5% between the doubled SrTiO$_3$ bulk lattice constant (0.3905 nm) and magnetite, it is possible to grow epitaxial Fe$_3$O$_4$ films on the SrTiO$_3$(001) surface [23,24]. In particular, concerning coupled Fe$_3$O$_4$/NiO bilayers grown on SrTiO$_3$, so far only Pilard et al. have reported on the magnetic properties of the Fe$_3$O$_4$/NiO interface [25]. On the other hand, NiFe$_2$O$_4$ thin films are of huge interest nowadays since they are magnetic insulators or semiconductors. Therefore, they can be used as spin filters [26] or for thermal induction of spin currents via the spin Seebeck effect [27,28]. Furthermore, electrical charge transport and spin currents can be manipulated by the spin Hall magnetoresistance using NiFe$_2$O$_4$ thin films adjacent to nonmagnetic material [29].

Therefore, we study here the possibility to form nickel ferrite starting with a distinct Fe$_3$O$_4$/NiO bilayer grown on Nb-doped SrTiO$_3$(001). Knowledge about the modification of the underlying crystallographic, electronic, and magnetic structure by Ni interdiffusion is indispensable for potential applications. We also want to investigate fundamental aspects, especially of Ni$^{2+}$ diffusion from a NiO buffer layer into a Fe$_3$O$_4$ top layer as well as NiO surface segregation through...
the Fe3O4 film, since knowledge of diffusion processes in oxides still appears to be quite rudimentary for many systems.

We perform a systematic three-step annealing cycle of Fe3O4/NiO bilayers after synthesis and simultaneously investigating surface crystallographic and “bulk” electronic structure changes by means of low energy electron diffraction (LEED) and hard x-ray photoelectron spectroscopy (HXAS).

Furthermore, we carry out structural analysis before and after the overall annealing cycle employing x-ray reflectivity (XRR) and synchrotron-radiation-based x-ray diffraction (SR-XRD), as well as element- and site-specific x-ray magnetic circular dichroism (XMCD) after the overall annealing cycle to analyze the resulting magnetic properties in detail.

II. EXPERIMENTAL DETAILS

Two samples with ultrathin Fe3O4/NiO bilayers on conductive 0.05 wt% Nb-doped SrTiO3(001) substrates have been prepared using the technique of reactive molecular beam epitaxy (RMBE). The substrates have been supplied with a polished surface and were annealed once at 400 °C for 1 h in an oxygen atmosphere of 1 × 10−4 mbar prior to deposition. Afterwards, the chemical cleanliness and composition was proven by XPS, while the crystallinity of the surface was checked by LEED. Oxide films have been deposited by thermal evaporation from pure metal rods in low oxygen atmosphere. During film growth, the substrate was heated to 250 °C, while the oxygen pressure was kept at 1 × 10−3 mbar for NiO and 5 × 10−6 mbar for Fe3O4 to guarantee optimal oxidation condition. Deposition rates of 0.85 and 4.6 nm/min were used for the growth of NiO and Fe3O4 films, respectively, which was controlled by a quartz microbalance adjacent to the source. One sample was created with a 5.6-nm NiO film (sample A), and the other was created with a 1.5-nm NiO film (sample B). Thereafter, 5.5-nm-thick Fe3O4 films were deposited on the NiO films. Film stoichiometry and surface structure have been monitored in situ by x-ray photoelectron spectroscopy (XPS) using Al Kα radiation and LEED, respectively.

The samples were transported under ambient conditions to the Diamond Light Source (DLS) synchrotron, where the effects of annealing on the bilayer system were studied at beamline I09 by heating the samples in three steps at 400 °C for 20 to 30 min in an oxygen atmosphere of 5 × 10−6 mbar to avoid reduction or further oxidation of the sample [30]. Prior to and after the annealing studies XRR measurements at 2.5 keV photon energy were performed to determine the film thickness. After each annealing step, the films were studied in situ by soft x-ray photoemission and HAXPES to clarify the chemical composition in the near-surface region and in the bulk region, respectively. In addition, LEED measurements were performed to check the crystallinity of the individual layers of the NiO/Fe3O4 bilayer.

For HAXPES an energy of hν = 9394 eV was used, creating photoelectrons with high kinetic energy, which allows a higher probing depth compared to soft x-ray photoemission (hν = 1000 eV).

The information depth D1, from which 95% of the photoelectrons originate, is defined as

\[ D_1(95) = -\lambda \cos \varphi \ln(1 - 95/100), \]

with the inelastic mean free path \( \lambda \) and the off-normal emission angle \( \varphi \) [31]. The maximum information depth for the Fe 2p core level for HAXPES and soft x-ray photoemission measurements is 22 and 2.5 nm, respectively, estimating \( \lambda \) with the Tanuma Powell and Penn algorithm (TPP-2M) formula [32]. As the beamline features a two-dimensional photoelectron detector, which can be operated in an angular mode, photoelectron spectra at different emission angles were acquired, each with an acceptance angle of ∼7°.

Subsequently, structural analysis of the annealed films was performed using SR-XRD, while the resulting film thickness and layer structure of these films were determined by means of laboratory-based XRR using Cu Kα radiation. SR-XRD experiments have been carried out ex situ at PETRA III beamline P08 (DESY, Germany) using a photon energy of 15 keV. In both cases the measurements were performed in θ-2θ diffraction geometry. For the analysis of all XRR experiments an in-house-developed fitting tool based on the Parratt algorithm [33] and Nérov-Croce roughness model [34] was used. The SR-XRD measurements were analyzed by calculating the crystal truncation rod (CTR) intensity within the full kinematic diffraction theory to fit the experimental diffraction data.

XMCD spectroscopy was performed at the Fe L2,3 and Ni L2,3 edges with the samples at room temperature at beamline 6.3.1 of the Advanced Light Source, Lawrence Berkeley Laboratory. We utilized total electron yield (TEY) as the detection mode. The external magnetic field of 1.5 T was aligned parallel to the x-ray beam and was switched for each energy. The angle between the sample surface and x-ray beam was chosen to be 30°. The resolving power of the beamline was set to E/ΔE ∼ 2000; the degree of circular polarization was about 55%. For the analysis of the Fe L2,3 XMCD spectra, we performed corresponding model calculations within the atomic multiplet and crystal-field theory including charge transfer using the program CTM4XAS [35,36].

III. RESULTS

A. Surface characterization

In Figs. 1(a)–1(c) the LEED patterns of the cleaned substrate and the as-prepared NiO and Fe3O4 films are presented for sample A. Figures 1(d) and 1(e) show the LEED images recorded after the last annealing step of 800 °C for sample A and sample B, respectively.

After cleaning of the SrTiO3 substrates the LEED pattern shows very sharp diffraction spots of a (1×1) surface with square structure and negligible background intensity [see Fig. 1(a)], indicating a clean (001)-oriented surface with long-range structural order. Additionally, XPS measurements show chemically clean substrates without carbon contamination (not shown here).

The LEED image recorded directly after RMBE of NiO also exhibits a quadratic (1×1) structure [see Fig. 1(b)], as expected for the NiO(001) surface unit cell. However, the pattern is rotated by 45° and is ∼√2 times larger than the pattern of the SrTiO3(001) substrate. The broadening of the diffraction spots is most likely caused by defects due...
demonstrating that Ni did not diffuse into the Fe$_3$O$_4$ film and visible for both samples due to the small information depth, (e) shows the LEED pattern for sample B after the final annealing step. Marked with red squares are the respective (1×1) surface unit cells in reciprocal space. The blue square indicates the (√2×√2)R45° superstructure typical for magnetite.

The LEED pattern of the as-prepared Fe$_3$O$_4$ film [see Fig. 1(c)] reveals a quadratic (1×1) surface structure with almost doubled periodicity compared to NiO as the real-space lattice constant of the magnetite inverse spinel structure is about twice as large, giving a lattice misfit of only 0.5% for Fe$_3$O$_4$(001) on NiO(001). Furthermore, additional diffraction spots of a (√2×√2)R45° superstructure can be seen, which is characteristic of well-ordered Fe$_3$O$_4$(001) surfaces [37–39].

LEED results indicate a cube-on-cube growth for both NiO and Fe$_3$O$_4$ films. Additionally, the Ni 2p and Fe 2p XPS spectra recorded directly after preparation of each film (not shown here) exhibit a characteristic shape for Ni$^{2+}$ and mixed Fe$^{2+}$/Fe$^{3+}$ valence states, respectively. Thus, combining the results from XPS and LEED, we can conclude that the as-prepared films consist of stoichiometric Fe$_3$O$_4$/NiO bilayers.

Figure 2 shows the Fe 2p and Ni 2p core-level spectra of both samples after transport to DLS under ambient conditions (sample A) and after each annealing step using soft XPS.

After the first annealing step at 400 °C, the Fe 2p peak shape is similar to that of the untreated sample [see Fig. 2(a)]. No charge-transfer satellites are visible, indicating Fe$_3$O$_4$ stoichiometry and the presence of a mixed oxidation state [40,41]. For both samples, Fe 2p$_{3/2}$ and Fe 2p$_{1/2}$ peaks are located at binding energies of 710.4 (±0.2) and 723.8 (±0.2) eV, respectively, corresponding to the values for magnetite known from the literature [40]. Furthermore, no Ni 2p signal is visible for both samples due to the small information depth, demonstrating that Ni did not diffuse into the Fe$_3$O$_4$ film and that the Fe$_3$O$_4$ film was not deconstructed [see Figs. 2(b) and 2(d)]. Consequently, the first annealing step at 400 °C only removed surface contaminations from the transport, without effecting the initial layer structure of the sample.

After the annealing step at 600 °C, a distinctive satellite typical for trivalent iron becomes visible between the Fe 2p$_{1/2}$ and Fe 2p$_{3/2}$ peaks for sample A and sample B [see Figs. 2(a) and 2(c)]. Further, Fe 2p$_{1/2}$ and Fe 2p$_{3/2}$ are shifted to binding energies of 710.9 (±0.2) and 724.4 (±0.2) eV, respectively. The shift to higher binding energies and the satellite at ~8 eV above the main peak confirm the presence of Fe$^{3+}$ and a deficiency of divalent iron [40–42].

In contrast to lower annealing temperature, Ni 2p peaks becomes visible after the 600 °C annealing step. Both samples show an intense Ni 2p signal consisting of two main peaks accompanied by satellite peaks at ~7 eV above their binding energies. The shape of the spectra and, in particular, the absence of a shoulder on the high-energy side of Ni 2p$_{3/2}$ indicates that no NiO cluster has been formed at the surface of both samples [43,44]. The occurrence of such a shoulder ~1.5 eV above the 2p$_{3/2}$ peak is reported to be characteristic of NiO [45,46]. The binding energy of 855.2 (±0.2) eV of the Ni 2p$_{3/2}$ peak also confirms the origin of NiFe$_2$O$_4$ and not of NiO [43,47]. Thus, both iron and nickel spectra obtained after annealing at 600 °C point to the formation of NiFe$_2$O$_4$ at the near-surface region of both samples as a result of intermixing.

The last annealing step at 800 °C influences the peak shape of neither the Fe 2p nor the Ni 2p spectra of sample B [see Figs. 2(c) and 2(d)], indicating a complete intermixing of the two layers already after the annealing at 600 °C. However, for sample A a NiO-specific shoulder on the high-energy side of Ni 2p$_{3/2}$ appears [see Fig. 2(b)]. Further, a shift to lower binding energies takes place, resulting in a binding energy of 854.5 (±0.2) eV for Ni 2p$_{3/2}$, indicating the presence of NiO at the surface [43]. Since there is no change in the Fe 2p spectra for sample A, we conclude that NiO clusters are formed at the surface of a NiFe$_2$O$_4$-like film.

FIG. 1. LEED patterns for sample A recorded directly after (a) preparation of the SrTiO$_3$ substrate, (b) deposition of NiO, (c) deposition of Fe$_3$O$_4$, and (d) the last annealing step of 800 °C. For comparison, (e) shows the LEED pattern for sample B after the final annealing step. Marked with red squares are the respective (1×1) surface unit cells in reciprocal space. The blue square indicates the (√2×√2)R45° superstructure typical for magnetite.

FIG. 2. Soft XPS spectra of (a) Fe 2p and (b) Ni 2p regions of sample A and (c) Fe 2p and (d) Ni 2p regions of sample B after each annealing step. For sample A the spectra of the untreated sample are shown exemplarily.
LEED patterns of samples A and B recorded after the final annealing step are presented in Figs. 1(d) and 1(e). The diffraction pattern can be attributed to the (001)-(1×1) surface of nickel ferrite, which shows a lattice constant similar to that of magnetite [see Fig. 1(c)]. However, the $\sqrt{2} \times \sqrt{2} R45^\circ$ superstructure indicative of magnetite is not observed after the final annealing step. Therefore, this result underpins the formation of nickel ferrite, as concluded before from XPS data after annealing [see Fig. 3(a)]. As concluded from the obtained dispersion $\delta$, the first layer on top of the substrate is a thin nickel oxide layer, while the second layer is an 8.2-nm-thick nickel ferrite film [48]. The third layer on top of the nickel ferrite film consists of an oxide layer with a diluted dispersion $\delta$ and thus a reduced electron density. Taking into account the NiO formation on top of sample A seen in the soft XPS spectra, we can attribute the upper layer to NiO segregation to the surface. The low electron density of this layer indicates a deconstructed film or island formation on the surface.

For sample B, however, the XRR is modeled with a single homogeneous 7.1-nm-thick nickel ferrite film [see Fig. 3(b)]. For both samples the thicknesses of the residual films almost coincide with the sum of the initial thicknesses of the Fe$_3$O$_4$ and NiO films.

The slight increase in the overall thickness can be attributed to a volume increase of $\sim 8\%$ due to the formation of nickel ferrite.

![Figure 3](http://example.com/figure3.png)

**Figure 3.** Reflectivity curves and calculations from XRR measurements before and after the annealing experiments (a) for sample A and (b) for sample B. The insets show the underlying models.

### Table I. Model parameters used for the XRR intensity calculations, with dispersion $\delta$, surface roughness $\sigma$, and film thickness $d$

<table>
<thead>
<tr>
<th></th>
<th>Substrate</th>
<th>Layer 1</th>
<th>Layer 2</th>
<th>Layer 3</th>
</tr>
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<tbody>
<tr>
<td></td>
<td>$\delta$</td>
<td>$\sigma$ (Å)</td>
<td>$\delta$</td>
<td>$\sigma$ (Å)</td>
</tr>
<tr>
<td>Sample A</td>
<td>As prepared$^a$</td>
<td>$1.48 \times 10^{-4}$</td>
<td>2.4</td>
<td>$2.15 \times 10^{-4}$</td>
</tr>
<tr>
<td></td>
<td>Annealed$^b$</td>
<td>$1.50 \times 10^{-5}$</td>
<td>0.1</td>
<td>$1.7 \times 10^{-5}$</td>
</tr>
<tr>
<td>Sample B</td>
<td>As prepared$^a$</td>
<td>$1.48 \times 10^{-4}$</td>
<td>2.7</td>
<td>$2.15 \times 10^{-4}$</td>
</tr>
<tr>
<td></td>
<td>Annealed$^b$</td>
<td>$1.50 \times 10^{-5}$</td>
<td>0.1</td>
<td>$1.58 \times 10^{-5}$</td>
</tr>
</tbody>
</table>

$^a$Measured at a photon energy of 2500 eV.

$^b$Measured at a photon energy of 8048 eV.
for NiO [43,47]. This shoulder almost completely disappears after annealing at 600 °C for both samples. Biesinger et al. [49] identified such a peak shape without a shoulder for the spinel-type material NiFe2O4. In addition, the Ni 2p3/2 peak is shifted to a higher binding energy of 855.0 (±0.2) eV, which is comparable to binding energy reported for Ni in NiFe2O4 stoichiometry [43]. The small mismatch between the measured value and the literature is due to an overlap of intensities originating from several layers with slightly different stoichiometries. In summary, similar to the soft XPS results, an exchange of Fe2+ ions with Ni2+ ions in the Fe2O3 spinel structure through interdiffusion seems to be likely [50].

For sample B, the peak shape does not change with the next annealing step at 800 °C [see Fig. 5(b)]. However, for sample A the shoulder on the high-binding-energy side re-appears, as observed for the initial bilayer system [see Fig. 5(a)]. Additionally, the Ni 2p3/2 peak is shifted to a lower binding energy, suggesting the formation of NiO-like structures, which is consistent with the NiO formation at the surface seen in the XRR and soft XPS measurements.

Furthermore, a quantitative analysis of the photoelectron spectra was performed to prove the formation of nickel ferrite. After subtracting a Shirley background, the intensities \( I_{\text{Fe}} \) and \( I_{\text{Ni}} \) of the Fe 2p peaks and the Ni 2p3/2 peak (due to the overlap with the Fe 2s peak, the Ni 2p3/2 peak has not been considered) have been numerically integrated. From these results, the relative photoelectron yield

\[
Y_{\text{Ni}} = \frac{I_{\text{Ni}}/\sigma_{\text{Ni}}}{I_{\text{Fe}}/\sigma_{\text{Fe}}} = \frac{N_{\text{Ni}}}{N_{\text{Ni}} + N_{\text{Fe}}C(\varphi)}
\]

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\]
of Ni has been calculated, using the differential photoionization cross sections $\sigma$ reported by Trzhaskovskaya et al. [51]. Newberg et al. [52] derived that this yield is equal to the atomic ratios but modified with a factor $C(\phi)$ that depends on the angle of photoemission (neglecting photoelectron diffraction effects). The resulting yields from different detection angles are plotted in Fig. 6. The curves from the data of the first annealing steps show for both samples a decreasing yield for higher emission angles, as indicated by the blue dashed lines. This behavior points to an intact stack of oxide films due to a longer pathway of the photoelectrons for higher emission angles. The lines are calculated for a stack of two separated $\text{Fe}_3\text{O}_4/\text{NiO}$ films using the thicknesses obtained from XRR analysis. With the successive annealing steps, the photoelectron yield from Ni increases, which indicates that there is diffusion of Ni into the $\text{Fe}_3\text{O}_4$ film and/or Fe into the NiO film.

Since there is no evidence of NiO in the Ni 2p HAXPES spectra after annealing at 600 °C, a model consisting of a stoichiometric 8.2-nm-thick NiFe$_2$O$_4$ on top of a 3.4-nm-thick NiO layer was used for sample A [green dashed line Fig. 6(a)].

With further annealing at 800 °C the intensity ratios [Fig. 6(a)] show a continuous increase of the nickel intensity. This indicates that more Ni atoms are diffusing/transported through the nickel ferrite layer to the very surface forming NiO as detected by XRR and soft XPS measurements. The photoelectron yield for this annealing step (dashed red line) was calculated using the layer structure and thicknesses obtained from the XRR analysis [see inset in Fig. 3(a)]. This model is based on a stoichiometric 8.2-nm-thick Ni$_{x}$Fe$_{3-x}$O$_4$ film with $x = 1$ between two NiO films. The supposed segregation behavior of Ni and the formation of NiO at the surface could be explained by its lower surface energy of 0.863 J/m$^2$ compared to the surface energy of 1.235 J/m$^2$ for NiFe$_2$O$_4$(001) [53]. Thus, one would expect an inversion of the initial bilayer ordering with NiO under magnetite. However, during the diffusion process Ni is partly incorporated in the initial magnetite film, and stoichiometric NiFe$_2$O$_4$ is formed. After saturation of the nickel ferrite the residual Ni starts to form NiO at the surface. In our case, however, this process is obviously not completed due to kinetic effects, and residual NiO is still underneath the nickel ferrite.

In the case of sample B one can conclude that a single homogeneous film was already formed by the interdiffusion process after the second annealing step. Its stoichiometry does not change from the second to the third annealing step [see Fig. 6(b)]. There is an annealing step after the second annealing step. Its stoichiometry does not change from the second to the third annealing step [see Fig. 6(b)]. The ratio of Ni and Fe, assuming a complete intermixing, can be determined from Eq. (2), as then the angular factor $C(\phi) \equiv 1$. The amount of nickel and iron does not match the ratio of 1:2 for stoichiometric nickel ferrite and is 1:2.6 for sample B, indicating an excess of Fe atoms. The experimental data are in good agreement with the calculated behavior (dashed red line) for a homogeneously mixed single layer, which is also consistent with the model obtained from XRR. Thus, the resulting stoichiometry of sample B is Ni$_{x}$Fe$_{3-x}$O$_4$, with $x = 0.83$.

The simulation of the photoelectron yield does not describe the measured data in full detail but gives an idea of the possible course. One limitation is that a model consisting of a stack of separated homogeneous layers was used. Thus, potential concentration gradients or clusters are not implemented in the simulation. Further, effects caused by x-ray photoelectron diffraction (XPD) are not considered. Nevertheless, the general trend is described well.

### D. SR-XRD

Figure 7 shows SR-XRD measurements and calculated CTR intensity along the (00$L$) direction close to the perovskite SrTiO$_3$(002)$_P$ and spinel (004)$_S$ Bragg peaks for both samples after annealing. Here, $L$ denotes the vertical scattering vector in reciprocal lattice units (r.l.u) with respect to the lattice constant of the SrTiO$_3$(001) substrate. Indices $P$ and $S$ indicate

![Figure 6](image1.png)  
**FIG. 6.** Relative photoelectron yield at different off-normal emission angles (a) for sample A and (b) for sample B. The dashed lines show the calculated intensities using the models obtained from XRR analysis.

![Figure 7](image2.png)  
**FIG. 7.** SR-XRD measurements along the (00$L$) direction and calculated intensities. The insets show the layer structures used in the calculation. The model is similar to that obtained from the analysis of the XRR (see inset in Fig. 3).
the bulk notation for perovskite-type and spinel-type unit cells, respectively.

For both samples a clear peak from the SrTiO$_3$(001) substrate at $L = 2$ and a broad Bragg peak originating from the oxide film around $L \approx 1.87$ is observed. The structural parameters, e.g., vertical layer distances, are determined by analyzing the CTRs by applying full kinematic diffraction theory. The structural models obtained from the XRD analysis coincide with the layer models used for the XRR calculations of the annealed samples (see insets of Figs. 7 and 3).

For sample A the model consists of a NiFe$_2$O$_4$ layer between two thin NiO films (see inset in Fig. 7). The distinct oscillations close to the Bragg peak of the oxide film (Laue fringes) can be clearly attributed to the nickel ferrite layer, indicating a well-ordered homogeneous film of high crystalline quality. The diffracted intensity originating from the NiO results in a broad peak underneath the Bragg reflection of the nickel ferrite due to the small film thicknesses of the NiO films which cannot directly be seen by the bare eye in the experimental data. Furthermore, the vertical lattice constants obtained from curve fitting are $c_{\text{NiO}} = 0.4177$ nm for the NiO films and $c_{\text{NFO}} = 0.8334$ nm for the NiFe$_2$O$_4$ layer. These results are in good agreement with the bulk values of $a_{\text{bulk}} = 0.4176$ nm and $a_{\text{bulk}} = 0.8339$ nm, respectively.

For sample B the Laue oscillations completely vanish, pointing to inhomogeneities within the film [see Fig. 7(b)]. This effect is possibly caused by the excess of Fe atoms in the film, as observed by HAXPES. However, the peak width is in accordance with the NiFe$_2$O$_4$ thickness of 7.1 nm. In addition, the vertical lattice constant $c_{\text{NFO}} = 0.8304$ nm obtained from the calculations confirms the presence of a strongly distorted structure of the annealed film since it is notably lower than the value of bulk NiFe$_2$O$_4$.

E. XMCD

XMCD has been employed after the overall annealing cycle to analyze the resulting magnetic properties element specifically after annealing at 800 °C. Figure 8 depicts the XMCD spectra of samples A and B performed at the Fe $L_{2,3}$ and Ni $L_{2,3}$ edges, respectively. Both samples show a strong Ni dichroic signal [see Fig. 7(a)], and in order to extract the spin magnetic moments we use the spin sum rule developed by Chen et al. [54]. The number of holes is determined from the charge-transfer multiplet simulations for each sample. We also account for the core-hole interactions which mix the character of the $L_3$ and $L_2$ edges [55,56] by considering the spin sum rule correction factors obtained by Teramura et al. [55]. We find a Ni spin moment of $0.51 \mu_B$/Ni atom and an orbital contribution of $0.053 \mu_B$/Ni atom, summing up to a total Ni moment of $0.56 \mu_B$ for sample A. In the case of sample B we derive $m_{\text{spin}} = 0.91 \mu_B$/Ni atom, $m_{\text{orb}} = 0.122 \mu_B$/Ni atom, and hence a total Ni moment of 1.03 $\mu_B$/f.u. The latter value is rather close to that recently found by Klewe et al. [57] on a stoichiometric NiFe$_2$O$_4$ thin film.

Turning to the Fe moments, we find strong indications that our heat and diffusion experiments lead to a Ni$_{x}$Fe$_{3-x}$O$_4$ layer or cluster formation in both samples. Since we obtain $m_{\text{spin}} = -0.028 \mu_B$ (+0.11 $\mu_B$)/Fe atom and $m_{\text{orb}} = +0.015 \mu_B$ (+0.007 $\mu_B$)/Fe atom at the Fe sites of sample A (sample B), we find very small net contributions to the overall magnetic moments. In comparison Klewe et al. [57] found an iron spin moment of around $0.1 \mu_B$/Fe atom and a further orbital contribution of around 10%–15% of that value. This indicates an (almost complete) structural inversion of the prior bilayer system; that is, the iron ions occupy in equal parts...
octahedral and tetrahedral positions within the crystal. Since the moments of these octahedrally and tetrahedrally coordinated cations are aligned antiparallel, the moments nearly cancel each other out in a perfect inverse spinel structure.

Figure 8(c) presents the charge-transfer multiplet calculations for the single iron cations in octahedral and tetrahedral coordination as well as the best fits to the experimental Fe $L_{2,3}$-XMCD spectra of samples A and B with (red) and without (blue) considering Fe$^{3+}_{\text{tet}}$ ions. The resulting lattice site occupancies are 16.3% Fe$^{3+}_{\text{oct}}$, 32.2% Fe$^{3+}_{\text{oct}}$, and 51.5% Fe$^{3+}_{\text{oct}}$ (42.6% Fe$^{3+}_{\text{oct}}$ and 57.4% Fe$^{3+}_{\text{oct}}$) for sample A and 24.0% Fe$^{3+}_{\text{oct}}$, 31.5% Fe$^{3+}_{\text{oct}}$, and 44.5% Fe$^{3+}_{\text{oct}}$ (55.6% Fe$^{3+}_{\text{oct}}$ and 44.4% Fe$^{3+}_{\text{oct}}$) for sample B when including (not including) Fe$^{3+}_{\text{oct}}$ ions in the respective fit. The result that, for sample A, over 50% are in Fe$^{3+}_{\text{oct}}$ coordination as to the calculations also corresponds to the small negative spin moment determined by the spin sum rule.

From the overall multiplet fits [Fig. 8(c)] one can clearly see that feature i [Fig. 8(b)] is very small if Fe$^{3+}_{\text{oct}}$ cations are not explicitly considered in the respective simulations. The origin of this feature in ferrites with inverse spinel structure other than magnetite is still not entirely understood [44,57,58]. In Fe $L_{2,3}$-XMCD spectra of both samples A and B peak i is significantly smaller than results obtained very recently for NiFe$_2$O$_4$ thin films grown by pulsed laser deposition (PLD) [44] but somewhat more intense than it is in the result of Klewe et al. [57]. Also, their corresponding multiplet simulation resembles our approach (not considering Fe$^{3+}_{\text{oct}}$ sites) rather well. The presence of peak i in the Fe $L_{2,3}$-XMCD of sample B can at least partly be explained by the lack of Ni$^{2+}_{\text{oct}}$ ions as to the HAXPES measurements. Since peak i also occurs in XMCD experiments on bulk material [58], one can think about several additional reasons for the presence of some Fe$^{3+}_{\text{oct}}$ ions. For instance, a small fraction of the Ni ions might be present in the form of Ni$^{3+}$ or coordinated on tetrahedral sites as a result of the interdiffusion process. Despite the fact that Ni$^{3+}$ prefers octahedral coordination, even measurements on NiFe$_2$O$_4$ bulk crystals indicate that a few of the Ni ions are on tetrahedral sites [58]. Furthermore, oxidation or reduction of a fraction of the Fe at the very surface of the thin films cannot be entirely excluded as the probing depth of the total electron yield is only around 2 nm at the Fe $L_{2,3}$ and Ni $L_{2,3}$ resonances of oxides [58,59].

For sample B we also recorded element-specific hysteresis loops at the Ni $L_3$ edge and the site-specific loops at Fe $L_3$ resonances for peaks i–iii [see Fig. 8(b)]. Figure 9 displays the resulting magnetization loops. One can see the ferrimagnetic ordering between the Fe$^{3+}_{\text{oct}}$ cations and the other Fe and Ni cations. For all octahedrally coordinated cations we probe in-plane open magnetization curves, whereas the Fe$^{3+}_{\text{oct}}$ cations exhibit a closed, paramagnetic magnetization curve. In the out-of-plane configuration we only probed the Ni sites (see insets in Fig. 9). Whereas recently reported values of the coercive field are on the order of $H_c = 0.1$ T or more for NiFe$_2$O$_4$ thin films [44,57,60], we find significantly lower values for hysteresis loops of the octahedrally coordinated cations [see Fig. 9(b)], although it is difficult to obtain exact values for $H_c$ as the magnetization curves are pretty flat. We want to point out rather flat magnetization curves appear to be typical also for NiFe$_2$O$_4$ epitaxial thin films [61] and nanoparticles [62]. A number of things might be responsible for the observed discrepancy; a strongly increased $H_c$ might be caused by exchange-coupled grains [60] or a high defect density [57], for instance. On the other hand, similar values for the coercive field measured here have been found for polycrystalline as well as epitaxial Ni$_x$Fe$_{3-x}$O$_4$ thin films [61]. The bulk value of NiFe$_2$O$_4$ has been reported to be 0.01 T [62], which is closer to the values obtained here.

**IV. SUMMARY AND CONCLUSIONS**

We investigated the modification of the crystallographic, electronic, and magnetic properties of Fe$_3$O$_4$/NiO bilayers due to thermally induced interdiffusion of Ni ions out of the NiO layer into the magnetite film. We annealed two bilayers [sample A (B) initially comprises 5.6 nm (1.5 nm) NiO and 5.5 nm (5.4 nm) Fe$_3$O$_4$] in three steps of 20–30 min in an oxygen atmosphere of 5×10$^{-6}$ mbar. LEED demonstrated the extinction of the magnetite-specific ($\sqrt{2} \times \sqrt{2}$)R45$^\circ$ superstructure; however, a spinel-like (1×1) surface structure occurred after the overall annealing cycle.

Structural analysis reveals that the annealing cycles lead to homogeneous layers of Ni$_x$Fe$_{3-x}$O$_4$. In the case of sample A consideration of an additional NiO layer on the surface and interface leads to the best agreement between calculated and experimentally observed XRR and SR-XRD results. For sample B SR-XRD indicates a strongly distorted structure.
with a vertical lattice constant of $c = 0.8304$ nm, whereas
the vertical lattice constant $c = 0.8334$ nm of sample A is
close to that of bulk NiFe$_2$O$_4$ ($d_{\text{bulk}}^{\text{NiFe}_2\text{O}_4} = 0.8339$ nm).

These findings are supported by the soft XPS and HAXPES
experiments. First, the formation of $\text{Fe}^{3+}$ upon annealing at
600 °C is confirmed by the shape and binding energy positions of
the $\text{Fe} 2p$ core level spectra. Further annealing at 800 °C
does not cause any changes in the $\text{Fe} 2p$ spectra. Second,
for sample B the shape and binding energy of the $\text{Ni} 2p$
spectra indicate the formation of an inverse spinel ferrite,
whereas in the case of sample A NiO characteristic features
first diminish after annealing at 600 °C and then reappear
after the entire annealing cycle at 800 °C. Due to surface
sensitivity soft XPS analysis clearly reveals the occurrence of
$\text{Ni}^{2+}$ in NiO stoichiometry in the near-surface region after the
last annealing step. Further, HAXPES analysis shows also an
increasing amount of NiO $\text{Ni}^{2+}$. This may be associated with
the much thicker initial NiO layer of sample A, leading to Ni
diffusion to the sample surface. We assume that NiFe$_2$O$_4$
is formed on top of the residual NiO film after the annealing
step of 600 °C, as observed in the soft XPS and HAXPES.
However, further annealing at 800 °C results in segregation
and formation of NiO on top of a well-ordered stoichiometric
NiFe$_2$O$_4$ of high crystalline quality. Thus, the nickel ferrite
is saturated by Ni if the ferrite assumes NiFe$_2$O$_4$ stoichiometry.
The residual Ni attempts to form NiO on top of the nickel
ferrite due to its lower surface energy compared to the surface
energy of nickel ferrite [53]. This process, however, is not
completed in our case, probably due to kinetic effects.

Furthermore, we determined a Ni:Fe ratio of 1:2.6 for
sample B and thus a resulting stoichiometry of Ni$_{0.83}$Fe$_{2.17}$O$_4$.
This is in accordance with the weak crystalline quality of
sample B seen in the XRD measurements.

We employed XMC with the internal magnetic
properties of the thin films resulting from the Ni interdiffusion
process. In excellent agreement with complementary charge-
transfer multiplet simulations, we found a strong increase of
the Fe$^{3+}$ coordinated cation fraction (around 50%) compared
to stoichiometric Fe$_3$O$_4$, resulting in very small Fe net mag-
netic moments as determined from the experimental XMC data
by applying the sum rules. The magnetic properties after
the annealing cycle are in both samples dominated by the
contribution of the Ni$^{2+}$ ions, which exhibit magnetic moments of
0.56 $\mu_B$/f.u. (sample A) and 1.03 $\mu_B$/f.u. (sample B). The
latter value corresponds quite well to the value very recently
reported for a stoichiometric NiFe$_2$O$_4$ thin film [57]. The lower
value found for sample A can be explained by the formation of
(antiferromagnetic) NiO-rich islands or clusters at the surface
of the sample which contribute to the Ni $L_{2,3}$-XAS signal
but not to the corresponding XMCD. Finally, element-specific
hysteresis loops performed on sample B show a rather small
in-plane coercive field. This is a further indication of the
formation of a magnetically well ordered NiFe$_2$O$_4$-like thin
film by means of thermal interdiffusion of Ni$^{2+}$ ions into
magnetite from Fe$_3$O$_4$/NiO bilayers.

In conclusion we presented a comprehensive study of epi-
taxially grown Fe$_3$O$_4$/NiO heterostructures and their structural
evolution due to Ni interdiffusion as a consequence of three
distinct thermal annealing steps. A multitechnique approach
tackling the structural, chemical, electronic, and magnetic
properties leads to a rather complete and conclusive picture
which is also in good agreement with corresponding model
calculations. We have demonstrated that it is possible to
synthesize Ni$_i$Fe$_{3-i}$O$_4$ thin films with compositions close
to stoichiometric NiFe$_2$O$_4$ with high crystalline quality by
thermally induced intermixing of distinct Fe$_3$O$_4$/NiO bilayers
grown on Nb-doped SrTiO$_3$(001). If the initial Fe$_3$O$_4$ and
NiO thin-film thicknesses can be controlled precisely, one
may obtain Ni$_i$Fe$_{3-i}$O$_4$ thin films with tunable band gap
employing this approach, which might be of interest for several
applications, e.g., in the field of spintronics (spin valves) or for
experiments concerning the spin Hall magnetoresistance [29]
and the spin Seebeck effect [27,28]. Thus, additional transport
effects based on either charge or spin currents can be amplified
or suppressed depending on the band gap properties of the
NiFe$_2$O$_4$-like material.

**ACKNOWLEDGMENTS**

Financial support from the Deutsche Forschungsgemein-
schaft (DFG; KU2321/2-1 and KU3271/1-1) is gratefully
acknowledged. We thank Diamond Light Source for access
to beamline I09 (SL10511-1) that contributed to the results
presented here. Additionally, parts of this research were carried
out at the light source PETRA III at DESY. We would like to
thank F. Bertram for assistance using beamline P08. Further-
more, part of this work was performed at the Advanced Light
Source, which is supported by the Director, Office of Science,
Office of Basic Energy Sciences, of the U.S. Department of
Energy under Contract No. DE-AC03-76SF00098.

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